

Precise sputtering experiments at TU WIEN

- **Preparation** of **thin QCM films** and **bulk samples** of (a few) well defined materials: e.g. Fe, fusion grade W and EUROFER (twin samples for investigations in UU and TUW)
- **Characterization** of all targets by **IBA in UU** and **XPS in TUW**
- **Inspection** of all used samples by **AFM** at TUW, check for suitable smoothness and use AFM images as simulation inputs (i.e.: SDTrimSP-3D)
- **Determination** of **total sputtering yields** for QCM film targets by TUW
- **Measure** & compare **angular distr. of sputtered atoms** for both film and bulk targets with **catcher-QCM** in TUW

Preparations to integrate a Vienna QCM into the setup at Uppsala University

- **Provide** current **CAD models** of the QCM holder to UU for integration into their target holder
- **Provide** virgin **QCM quartzes** for coating (see above)
- **Construction** of dedicated **HF-Electronics** at TUW (to be installed at UU during the ENR project)

SDTrimSP simulations at TUW

- **Develop** a GUI for SDTrimSP for easy input
- **Changes** to the SDTrimSP code to allow an easy switching between different interaction potentials and a variation of electronic stopping power input
- **Simulations** with SDTrimSP for all used materials to determine sputtering yields and angular distributions of sputtered particles & backscattered projectiles
- **Check**, whether samples are sufficiently flat to be treated by SDTrimSP-1D by comparing results to SDTrimSP-3D simulations based on AFM images
- **Investigate** how sensitive the simulations are on a variation of the used interaction potential
- **Investigate** how sensitive the simulations are on a variation of the used electronic stopping values